

## **2. Rapid Thermal Synthesis System (MEL 2218)**

Intelsi-R series “bench Top” rapid thermal process (RTP) system is used for rapid thermal annealing under vacuum or various gas environments.

### **Features:**

- Process sample size up to 2” wafer size.
- High capacity vacuum pumping.
- Rapid heating rate: 100 °C/sec (212 °F/sec).
- Digital display readout and full computer control.

